

Breaking the Energy Barrier in Two-Photon Polymerization Using Strain-Activated Photochemistry

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Two-photon polymerization (2PP) has emerged as a powerful technique for high-resolution three-dimensional microfabrication; however, its broader application is often constrained by the requirement for high laser intensities and limited photochemical efficiency of conventional photoinitiators. In this work, we present a novel approach to 2PP based on strain-activated photo-dehalogenation, enabling efficient radical generation under significantly reduced energy input. The investigated system employs mechanically strained molecular precursors that undergo photoinduced bond cleavage upon single- and two-photon excitation, producing reactive species capable of initiating polymerization [1-3].

Our results demonstrate that the incorporation of strain-activated chromophores enhances the sensitivity of the photochemical process, allowing for low-threshold two-photon absorption and improved spatial control during fabrication. Comparative studies reveal that this mechanism not only lowers the required laser power but also expands the accessible processing window, facilitating finer feature definition and reducing photodamage. Furthermore, the dual capability of one- and two-photon activation provides additional flexibility in tuning fabrication conditions and material response. This strategy opens new avenues for the design of next-generation photoinitiating systems tailored for advanced 2PP applications, including micro-optics, biomedical scaffolds, and functional microdevices. By leveraging strain-induced reactivity, the proposed method contributes to overcoming key limitations in current photopolymerization technologies, paving the way toward more energy-efficient and versatile 3D microfabrication processes [2, 3].

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